

INFORMATION DISCLOSURE STATEMENT BY APPLICANT PTO FORM 1449	ATTY. DOCKET NO. 10191/1629	SERIAL NO. Not yet assigned
	APPLICANT(s) Franz LAERMER et al.	
	FILING DATE Herewith	GROUP Not yet assigned

U. S. PATENT DOCUMENTS

EXAMINER INITIAL	PATENT NUMBER	PATENT DATE	NAME	CLASS	SUBCLASS	FILING DATE
K-CC	5,047,115*	September 10, 1991	Charlet et al.	—	—	—
K-CC	4,855,017*	August 8, 1989	Douglas	—	—	—
K-CC	5,458,734*	October 17, 1995	Tsukamoto	—	—	—
K-CC	4,726,879*	February 23, 1988	Bondur et al.	—	—	—
K-CC	5,498,312*	March 12, 1996	Laermer et al.	—	—	—

*Copy of reference is not enclosed because reference is cited in Search Report (copy of reference provided by International Searching Authority).

FOREIGN PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB-CLASS	TRANSLATION	
						YES	NO
K-CC	EP 0 200 951	12 November 1986	Europe	—	—	X*	
K-CC	EP 0 414 372	27 February 1991	Europe	—	—	X*	
K-CC	DE 197 06 682	27 August 1998	Fed. Rep. of Germany	—	—	X*	
K-CC	JP 08 134 651	28 May 1996	Japan	—	—	X*	
K-CC	DE 42 41 045	26 May 1994	Fed. Rep. of Germany	—	—	X**	
K-CC	DE 43 17 623	1 December 1994	Fed. Rep. of Germany	—	—	X**	

*Copy of reference is not enclosed because reference is cited and described in Search Report (copy of reference provided by International Searching Authority).

**Described in the above-identified application.

OTHER DOCUMENTS

EXAMINER INITIAL	AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.	
K-CC	Flamm, D. et al.: "Multipel-Etchant Loading Effects And Silicon Etching In CIF/sub 3/ And Related Mixtures" Journal Of The Electrochemical Society, Dec. 1982, USA, Bd. 129, Nr. 12, pp. 2755-2760.	
K-CC	Patent Abstracts of Japan, Vol. 1996, No. 09 (30/09/1996).	

EXAMINER	DATE CONSIDERED
K-CC	10-7-93

EXAMINER: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.